31. Consider that in an n-type GaAs semiconductor at 300k temperature, the e-concentration varies linearly from 1×10¹⁸ to 7×10¹² cm⁻³ over a distance of 0.10cm. So, Calculate the diffusion current density if e-diffusion coefficient is Dn= 225 cm²/s.

Solul. Diffusion Current density is

Jdiff = e Dndn & e Dn An

Dx

So, as per value

Jdiff=1.6×10¹⁹×225 × (1×10⁸-7×10⁷)

=108 Alcm² Ans

32. Consider a p-type Si sample for which the hole diffusion coefficient is 9cm²/sec. If the hole concentration varies from 106 cm³ to 1013 cm³ over a length of lum, then find out the diffusion current density.

 93. Find the position of fermilerel Exat room tempe- 2 rature (=27°c) for Germanium crystal having 5×1022 atoms/m3. Ans3. Given T=27°c =300K and ne = 5x1022 atoms/m3 ne = 2 (2 mm kT) 2 (EF-EC) kt $= e^{\left(E_{p}-E_{c}\right)/kT} = \frac{ne}{2\left(\frac{2\pi me^{*}kT}{h^{2}}\right)^{3/2}}$ $= e^{(E_{P}-E_{9}/kT)} = \frac{5 \times 10^{22}}{2 \left[\frac{2 \times 3.14 \times 9.1 \times 10^{-31} \times 1.38 \times 10^{23} \times 300}{(6.62 \times 10^{-34})^{2}} \right]^{3/2}}$ = e (Ep-Ec)/kT = 5×10²²
25.115×10²⁴ e-(Ec-EF)/KT = 0.1991 ×102 e-(Ec-EF) | kT = 502.296 or Ec-EF = log 502.296 Ec-EF = 6.2192 or Ec-EF = 0.161 eV

84- For an intrinsic Semiconductor having band gap Eg=0.7eV Calculate the density of holes and electrons at room temperature (= 27°C). Given h = 6.62×10³⁴, m=9.1×10³
T= 3.14 & k=1.38×10⁻²³

Soln 4- Given Eg= 0.7eV

In intrinsic semiconductor the concentration of electrons and holes are same. So

Ne=nh= 2 [2xkTm]3/2 (EF-EC)/kt

The fermi level lies exactly in between the middle of conduction and valence band.

$$E_{f} = \frac{E_{c} + E_{v}}{2}$$

 $E_{f}-E_{c}=\underbrace{E_{c}+E_{v}}_{2}-E_{c}=-\underbrace{\left(E_{c}-E_{v}\right)}_{2}-\underbrace{E_{g}}_{2}$ $\therefore n_{e}=n_{h}=2\underbrace{\left[\frac{\partial xkTm}{h^{2}}\right]}_{e}-\underbrace{E_{g}/2kT}$

 $=2x\left[\frac{2\times3.14\times1.38\times16^{23}\times300\times9.1\times16^{31}}{6.62\times16^{34}}\right]e^{-\left[\frac{0.7}{2\times0.026}\right]}$

= 3.6 ×10 /m3.

Q5- A single solar cell (10cm × 10cm) produces a voltages of 0.5 v and a current upto 0.25 A. If the solar insulation is 800 W/m3, find the efficiency of solar cell? Solns- Surface Insulation (S.I.) = 800W/m², V=0.5V, ISTO I= 2.5 A. , n= 9. n = Pout x 100 where Pont = Voltage (V) x current (I) Pin = S. Ix area. η = VI SIX area = η = 800 × 10⁻² n= 0.1562 = 15.62% 06 - Solar insulation on a rectangular module (1.5m x 2.0m) of photo voltaic cell is 550 W/m2. If the efficiency of cell is 12%. What is the power output of the module? 80/n 6- n= Pont x 100 n= Pout = 0.12 = 12%.
Areax S. I = 0.12×550×3 0.12 = Pout 550 × 3 = 198W

O7. Calculate the drift relocity of e-in an aleminium wire of diameter 0.9 mm carrying current of 6A. dosume that 4.5 × 1028 et./m³ are available for conduction. Soln- I=6A, n=4.5x1028el/m3 & radius (r) = = = 09x103 = 45×104m Consent A = $\frac{6.0}{7 \times (4.5 \times 10^{-4})^2}$ = $\frac{6.0}{3.14 \times (4.5 \times 10^{-4})^2} = 9.44 \times 10^6 \text{ A/m}^2$ & drift relocity vd = I = 9,44 × 106

4,5 × 1028 × 1.6 × 1019 = 1.311 × 103 m/sec-